



gaw

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

NAKAMURA, Yasunori, et al.

Group Art Unit: 1713

Serial No.: 10/629,857

Examiner: William K. Cheung

Filed: July 30, 2003

P.T.O. Confirmation No.: 6154

FOR: POLYPROPYLENE-BASED RESIN COMPOSITION FOR A METALLIZED
FILM, FILM USING THE SAME TO BE SUBJECTED TO METALLIZING
AND METALLIZED FILM USING THE SAME

REQUEST FOR RECONSIDERATION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Date: February 9, 2007

Sir:

Reconsideration of the rejection contained in the Office Action dated November 29, 2006, in the above-identified application in view of the following detailed comments is respectfully requested.

In the Office Action, claims 1, 3 and 7 were rejected under 35 USC § 102(b) as being anticipated by, or alternatively, under 35 USC 103(a) as being obvious over, the patent to Chatterjee. In so doing, the same reasons were relied upon in making this rejection over the Chatterjee patent as were set forth in the prior Office Action. Reconsideration of this rejection in view of the following comments is respectfully requested.